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JC16 RECU PCT/PTO 22 MAY 20021

PATENT Docket No. 360842008500

CERTIFICATE OF HAND DELIVERY

I hereby certify that this correspondence is being hand filed with the United States Patent and Trademark Office in Washington, D.C. on May 22, 2002.

N. DeRiggi

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Hiroyuki NIWA et al.

Serial No.: 10

10/069,136

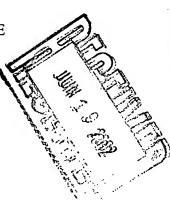
Filing Date:

February 22, 2002

For:

POSITIVE TYPE RADIATION-SENSITIVE COMPOSITION AND PROCESS FOR PRODUCING PATTERN WITH THE SAME Examiner: Unassigned

Group Art Unit: 1752



REQUEST FOR A CORRECTED FILING RECEIPT

Office of Initial Patent Examination Commissioner for Patents Washington, D.C. 20231

Sir:

Please furnish the undersigned with a corrected Filing Receipt for the above-identified application. The corrections needed are as follows:

The title should be POSITIVE TYPE RADIATION-SENSITIVE COMPOSITION AND PROCESS FOR PRODUCING PATTERN WITH THE SAME.

A copy of the marked-up Filing Receipt is attached.

In the event that the transmittal letter is separated from this request and the Patent Office determines that a fee is required, applicant petitions for any required relief including extensions

of time and authorizes the Commissioner to charge the cost of such petitions and/or other fees due in connection with the filing of this document to **Deposit Account No. 03-1952**.

Respectfully submitted,

Dated: May 22, 2002

By:

Barry E. Bretschneider Registration No. 28,055

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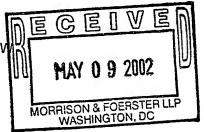


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APPLICATION NUMBER | FILING DATE | GRP ART UNIT | FIL FEE REC'D | ATTY.DOCKET.NO | DRAWINGS | TOT CLAIMS | IND CLAIMS | 10/069,136 V | 02/22/2002 | 1752 | 1188 | 360842008500 | 20 | 1

Barry E Bretschneider Morrison & Foerster 2000 Pennsylvania Avenue N V Washington, DC 20006-1888



CONFIRMATION NO. 1671
FILING RECEIPT
OC0000000007956381

Date Mailed: 04/29/2002

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Hiroyuki Niwa, Shiga, JAPAN; Kazutaka Tamura, Shiga, JAPAN; Masahide Senoo, Osaka, JAPAN;

Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP01/00315 01/19/2001

Foreign Applications

JAPAN 2000-187335 06/22/2000 JAPAN 2000-192298 06/27/2000

Projected Publication Date: To Be Determined - pending completion of Security Review

Non-Publication Request: No

Early Publication Request: No

Title

Positive type radiation-sensitive composition and process for processing for producing pattern with the same

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